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## INFORMATION REPORT

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## CENTRAL INTELLIGENCE AGENCY

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Zavod 393, Krasnogorsk 25X1  NO. OF PAGES  9	COUNTRY	USSR (Moscow Oblast)	REPORT	
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	chief. Ustinov visited the shops and laboratories three or four times. particularly those in the old area.
1	a Soviet named Karvinskiy (fnu) was a charge of the entire installation, including both the old and new areas. After the separation of the old and new areas, Karbinskiy had nothing more to do with the new plant. Major General Nikolayev was in charge of SKB-1 (Construction and Development Bureau No. 1) and Belayev was in charge of SKB-2. Wikolayev had already been interested in the Kiel device in Jena.
	member of the Leningred Omtion Transit in
Th	member of the Leningrad Optical Institute, the same institute which ordered e spectrograph, came with production problems regarding these mirrors. ey made their first inquiries for Kiel mirrors in 1948, but it was not until 49-50 that they wanted the mirrors produced in quantity.
Be:	fore the end of World War II, Zeiss had production line facilities for Juno mess which had practically eliminated hand work.

	any work Ing. Otto Ritter may have done on the Juno was	
	primarily of the nature of translating German to Soviet norms rather than to produce a new design.	
L	Black Bodies	
	Prior to 1949, no work done in Krasnogorsk on black bodies.  After 1949, the Germans received a military production order for about 20 to	
	30 black bodies.  page 8): They were in a wooden housing approximately 35 to 40 cm. The housings were painted field gray, identical in color with military aircraft cameras made at the same installation. There was a carrying handle on the top, which included a visor at the same time. An opening in the center, with a removable cover, represented the source of radiation. A plug for the heater	
	current was located in the rear.  a separate battery was supplied with the unit. The black body was insulated from the wooden case.	05.74
	The units were not equipped with built-in thermometers  the Soviets inserted a thermometer in the center opening to measure temperature.	25X1
	were produced for the Soviets, under the direction of Straubel, between 1950 to 1951. Difficulties were encountered during production and some of the units had to be returned by the Soviets for repair. This caused considerable concern, in as much as Nikolayev was responsible for the order covering these black bodies, which had the highest priority. Naturally, the plant management was very much interested in the completion of the order.	25X1
	the black bodies were tested by the Soviets in the old area at a range of about 20 meters. When completed the black bodies were turned over to an Army field office, located in the old area, which accepted all military equipment produced at the Krasnogorsk installation. A Soviet Army colonel, with a staff consisting partly of Air Force officers, was in charge of this office.	
	Straubel had also worked on a requirement for a special laboratory black body equipped with a cooling system.	
	KRS - 5 Optical Work	
	Straubel came to Zeiss after the end of World War II and took over the crystal laboratory there as successor to Smakula (fnu). His work covered the growth of KRS-5 crystals and rocksalt crystals. The ovens were repaired in 1945 and set up in the so-called Eulengebauede in Jena. The first experimental crystals were grown when Straubel was required to dismantle the equipment in Jena and to reassemble it in Krasnogorsk, primarily for KRS-5 production. He reestablishe the laboratory at Krasnogorsk, with four or six ovens, in the old building.  the quality of the crystals grown at Krasnogorsk was	
	inferior to those formerly made at Zeiss in Jena. They were softer and difficulties were experienced in working these crystals.	
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			used liquid air in conjunction with his vacuum systems in 1947 and he might have used liquid air for cooling of photocells.	

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-6-

		25 <b>X</b> 1
28.	Goerlich was experimenting with lead selenide and lead telluride cells, as a result of a Soviet requirement, sometime between 1949 to 1951. Source felt that Goerlich had already started work on this problem in the old building but continued to work in the new building on it.	
	Goerlich had been originally working on evaporated cells in the old building but later discontinued this work and switched to chemical disposition when the Soviets required it.	25 <b>X</b> 1
29.	evaporated cells were later made in the Soviet laboratory, in the old building, since Goerlich once had to assist when the number of cells	25 <b>X</b> 1
	delivered per month was inadequate.  approximately 60 to 100 evaporated cells per month were made by the Soviets, and that 50 to 60 Elac-type cells per month were made by Goerlich after 1949-50.	25 <b>X</b> 1
30.	there was simultaneous work going on with evaporated	25 <b>X</b> 1
	and chemically deposited cells in the Soviet laboratory but rather that one or the other type was made at any one time.  an evaporated cell which looked different than the Elac cell and was actually a square	25 <b>X</b> 1
		25X1 25X1
	there was no flask type space for a cooling agent;	25 <b>X</b> 1
	(Figure 3, page 9, shows the cell.) The surface was a velvet gray layer.  Goerlich's	25X1
	laboratory when the Soviets could not fulfill their requirements - in which case the new laboratory had to assist in production.	25X1
	lead telluride or lead selenide cells.  Goerlich was working	25X1
31.	a Soviet PbS photocell when a spectrograph or similar device was developed at Krasnogorsk. This device was ordered by a Moscow institute of physics and the cells were furnished for this equipment by the Soviets. The Soviet cells were never directly compared with those of Goerlich but collaborators of Goerlich, Dr. Paul Gaenswein particularly, pointed out that the Soviet cells were substantially better than those which	25X1
	the Germans themselves were making at that time.	25X1 25X1
	graph. They were a little larger than the evaporated Krasnogorsk type and were fitted with a different base (see Figure 4, page 9).	25X1
	a quartz prism was to be used in the spectrograph but was not certain whether the quartz prism was the only one used in the equipment. The Krasnogorsk laboratory had refused to furnish rocksalt and quartz prisms because they were	
	not in a position to brient quartz prisms, having no equipment for this, nor did they have facilities to work rocksalt. Such prisms were furnished from somewhere else.	25 <b>X</b> 1
		~~~
		25X1
32.		•

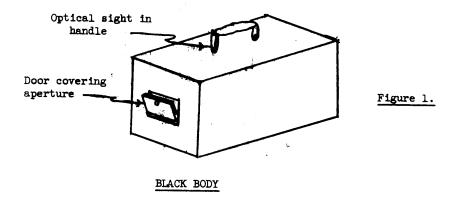
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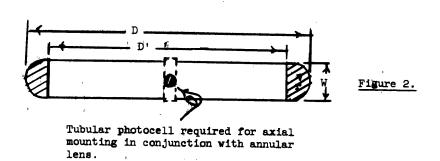
25X1

	Soviet Optical I	ndustry	2
far advance period of a to those was some excell USSR in tha	, starting after the Revold that it was capable of a pproximately one year, exceed by Zeiss. The Soviets	reproducing, in the compar cellent Sonnar objectives have fine institutes whi world has one great adva mastered the principles	s presently so atively short of equal quality ch have developed ntage over the of transferring
<u></u>			nt which even
the German	_ the Soviets have develor	oed a synthetic lens ceme	nt which even
Leningrad hadevices. So at Krasnogo: Leningrad us the Leipzig making satis	Zeiss in Jena h Fair in 1954 and that this sfactory thermal detectors	nd was on par with German ces of recent manufacture clometer allegedly originary.  ad demonstrated a spectra s means that evidently pro- had been overcome.	n and English e were in use ating in ophotometer at roblems of
which compri		ute, known as GOI (State	glass techniques
Institute when the continuous con	Fifilov, a profess titute of physics, was te there was a large optical ere such personalities ar- ives; Kummanyen who is ch cal industry; Aleksandrov l as such scientists as Ms	development center at the employed as Yachendov, wife of a group for equipment in charge of optical ar	th's book. 2 the Leningrad tho works on thent development thereby development

S-E-C-R-E-T

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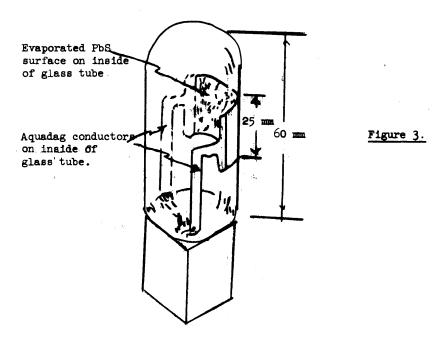
Approx.dimensions:
 D = 190 mm
 D' = 170 mm
 r = 25 to 30 mm
 W = 20 to 25 mm

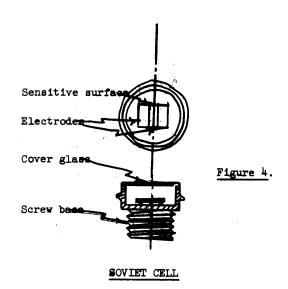
Note: The dimensions given do not quite check out, structurally, but are indicative of the order of magnitude.

## SPECIAL ANNULAR LENS

25X1

-9-





S-E-C-R-E-T